2SK2586

Silicon N-Channel MOS FET

HITACHI

ADE-208-358 C 4th. Edition

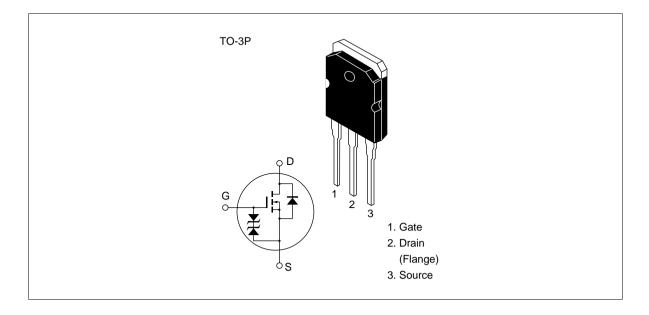
Application

High speed power switching

Features

- Low on-resistance
- $R_{DS(on)} = 7 \text{ m typ.}$
- High speed switching
- 4 V gate drive device can be driven from 5 V source

Outline





2SK2586

Absolute Maximum Ratings $(Ta = 25^{\circ}C)$

Item	Symbol	Ratings	Unit
Drain to source voltage	$V_{ t DSS}$	60	V
Gate to source voltage	V _{GSS}	±20	V
Drain current	I _D *2	60	A
Drain peak current	l _{D(pulse)} *1	240	A
Body to drain diode reverse drain current	I _{DR} *2	60	A
Avalanche current	I _{AP} *3	45	A
Avalanche energy	E _{AR} *3	174	mJ
Channel dissipation	Pch*2	125	W
Channel temperature	Tch	150	°C
Storage temperature	Tstg	-55 to +150	°C

Notes: 1. PW \leq 10 μ s, duty cycle \leq 1 %

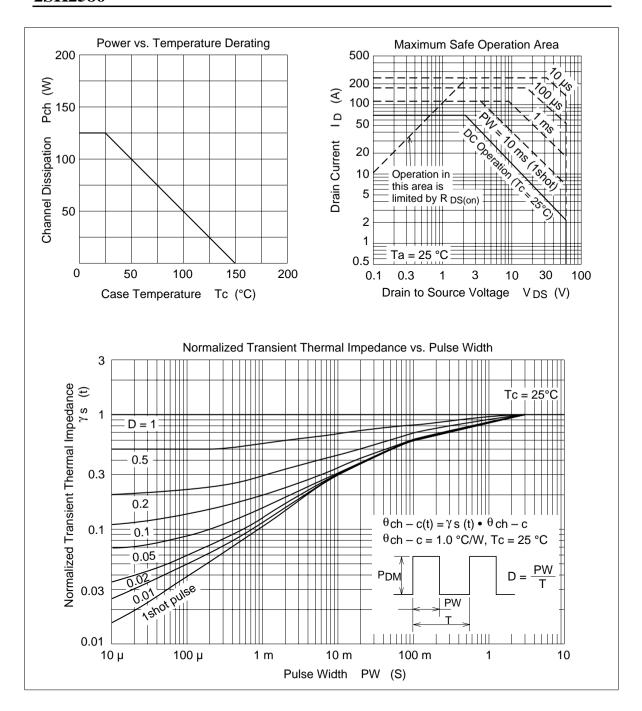
- 2. Value at Tc = 25°C
- 3. Value at Tch = 25°C, Rg \geq 50 Ω

Electrical Characteristics ($Ta = 25^{\circ}C$)

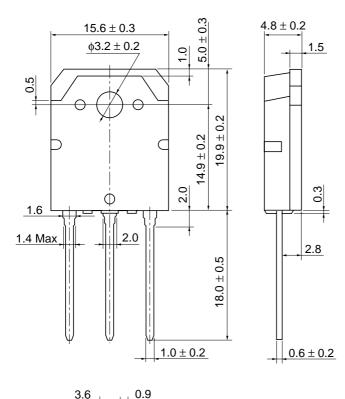
Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	60	_	_	V	$I_D = 10 \text{ mA}, V_{GS} = 0$
Gate to source breakdown voltage	$V_{(BR)GSS}$	±20	_	_	V	$I_G = \pm 100 \ \mu A, \ V_{DS} = 0$
Gate to source leak current	I _{GSS}	_	_	±10	μΑ	$V_{GS} = \pm 16 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I _{DSS}	_	_	100	μΑ	$V_{DS} = 60 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.0	_	2.0	V	$I_{D} = 1 \text{ mA}, V_{DS} = 10 \text{ V}$
Static drain to source on state resistance	$R_{DS(on)}$	_	7	10	mΩ	$I_D = 30 \text{ A}$ $V_{GS} = 10 \text{ V}^{*1}$
		_	10	16	mΩ	$I_D = 30 \text{ A}$ $V_{GS} = 4 \text{ V}^{*1}$
Forward transfer admittance	$ y_{fs} $	35	60	_	S	$I_D = 30 \text{ A}$ $V_{DS} = 10 \text{ V}^{*1}$
Input capacitance	Ciss	_	3550	_	pF	$V_{DS} = 10 \text{ V}$
Output capacitance	Coss	_	1760	_	pF	$V_{GS} = 0$
Reverse transfer capacitance	Crss	_	500	_	pF	f = 1 MHz
Turn-on delay time	$t_{\text{d(on)}}$	_	35	_	ns	$I_{D} = 30 \text{ A}$
Rise time	t_{r}	_	260	_	ns	$V_{GS} = 10 \text{ V}$
Turn-off delay time	$t_{d(off)}$	_	480	_	ns	$R_L = 1.0 \Omega$
Fall time	t _f		370		ns	
Body to drain diode forward voltage	V_{DF}		0.94		V	$I_F = 60 \text{ A}, V_{GS} = 0$
Body to drain diode reverse recovery time	t _{rr}	_	140	_	ns	$I_F = 60 \text{ A}, V_{GS} = 0$ diF / dt = 50 A / μs

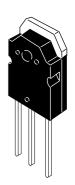
Note: 1. Pulse Test

See characteristic curves of 2SK2529.



Unit: mm





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5.45 ± 0	0.5					5.4	45 ±	0.5

Hitachi Code	TO-3P
JEDEC	
EIAJ	Conforms
Weight (reference value)	5.0 g

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